FIRST PRINCIPLES ELECTRONIC STRUCTURE CALCULATIONS for NANOMATERIALS MODELING



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1. MOTIVATION

During the last decade, new and strong demands are posed to materials since the development of promising technologies in key domains - such as Energy, Environment and Information Technology - is restricted by the lack of materials with adequate properties.

Computational Materials Modeling emerges as a powerful tool in the development of future technologies.

2. Density Functional Theory (DFT) Framework

Main goal: given the chemical composition and the geometrical structure of a system, to calculate its properties by solving the electronic Schrodinger equations - a correlated many body problem (solved only approximately, yet).

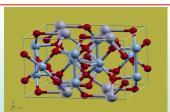
- No usage of empirical information or free parameters.

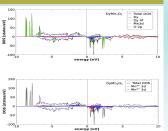
3.1 RMn205

- Multiferroic properties, Outstanding coupling between the magnetic and ferroelectric modes [1,2]. Crystal structure: Infinite chains of Mn4+O6 octahedra, linked through [Mn3+O5] pyramidal units and bicapped antiprisms [RO8] [3].
- Magnetic structure : Complex AF order at low T, amplitude modulated.

References

- [1] W. Eerenstein et al., Nature 442 (2006) 759. [2] Y Noda et al J. Phys.: Condens.
- Matter 20 (2008) 434206 [3] J.A. Alonso et al., *J. Phys.:* Condens. Matter 9 (1997) 8515.



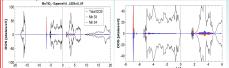


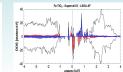
3.2 TM: $TiO_{2-\delta}$ anatase phase.

- DMS films for spintronic devices [1].
- Evaluation of direct TM-TM exchange; OV-s role ? [2]
- L(S)DA results:
- AF ground state: Mn and Fe doping;
- FM or AF for Co doping (OV-s conc.).
- TM electronic configuration: M2+;
- Two spin configurations of the TM may coexist
- OV-s increase by 20-30 %the direct TM-TM exchange strength.

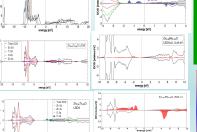
References

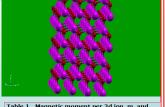
[1] R. Janisch, N. A. Spaldin, Phys. Rev. B 73 (2006) 035201. [2] N. Plugaru, R. Plugaru, Psi-k 2010 Conf., Berlin, Germany, to be published.





3.3 DMS: TM:ZnO wurtzite-type



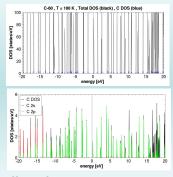


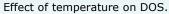
x (3d)	(at.%)	2	5	10
m (µ _B /at)	Ti	0.90	1.13	1.28
	Mn*)	4.71 (4.97)	4.71 (4.97)	4.71 (4.97)
M (μ _B /f.u.)	Ti	0.02	0.06	0.13
	Mn	0.10	0.25	0.50

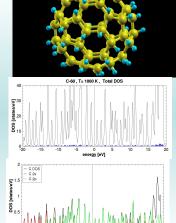
The description of electrical conductivity in disordered ZnO: a lasting challenge due to the entanglement of magnetism and charge/spin transport. References

R. Plugaru and N. Plugaru, Psi-k 2010 Conf. Berlin, Germany, September 12-16, 2010. to be published.

3.4 Carbon nanostructures: C60







OUTLOOK

Three good reasons for performing **Computational Materials Modeling**

- 1. High throughput calculations become economically relevant.
- 2. Increasing accuracy in the predictions, approaching more and more to real world.
- 3. It provides an insight where experiment has little access, if at all (materials for nuclear activities, strong fields, high pressures and temperatures, complex molecular devices, etc.)

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